## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : James S. Im Customer No. : 21003

Serial No. : 10/525,297 Confirmation No. : 6004

Filed : 2/15/2005 Group Art Unit : 2811

Examiner : Bac H. Au

For : Process And System For Laser Crystalization Processing Of Film Regions

On A Substrate To Minimize Edge Areas, And A Structure Of Such Films

Region

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. §§ 1.56 and 1.97(b), applicants bring to the attention of the Examiner the documents listed on the attached Form PTO 1449 and respectfully request that the listed documents be considered by the Examiner and made of record in the above-captioned application. Copies of all U.S. Patents and Applications are not enclosed pursuant to the waiver of 37 CFR 1.98 (a)(2)(ii) for all applications filed after June 30, 2003.

This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that the listed documents are material or constitute "prior art." If the Examiner applies the documents as prior art against any claim in the application and applicants determine that the cited documents do not constitute "prior art" under United States law, applicants reserve the right to present to the Office the relevant facts and law regarding the appropriate status of the documents.

Atty. Docket No. 070050.2717
PATENT

Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the listed documents, should the documents be applied against the claims of the present application.

Applicants believe no fee is due in connection with this submission. If any additional fee is due, or if any overpayment has been made, the Commissioner is authorized to charge any such fee or credit any overpayment, to our Deposit Account No. 02-4377.

Respectfully submitted,

BAKER BOTTS L.L.P.

June 6, 2007

Date

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| Form PTO-1449 U.S. Department of Commerce (REV. 2-82) Patent and Trademark Office | Atty. Docket No. 070050.2717 | Serial No.<br>10/525,297 |
|---|------------------------------|--------------------------|
| INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)   | Applicant James S. Im        |                          |
|   | Filing Date 2/15/2005        | Group<br>2811            |
|   | Examiner<br>Bac H. Au        |                          |
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## FOREIGN PATENT DOCUMENTS

| Exam<br>Initial | No. | Document No. | Publication Date | Applicant(s)  |
|-----------------|-----|--------------|------------------|---|
| Illitia         | 1.  | WO 0197266   | 12/20/2001       | Mitsubishi Denki Kabushiki Kaisha                           |
|                 | 2.  | WO 0171791   | 09/27/2001       | The Trustees of Columbia University In The City of New York |
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|---------------|-----------------|
| Examiner      | Date Considered |
|               |                 |

<sup>\*</sup> Examiner: Initial citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.